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AMENDMENT TRANSMITTAL LETTER (Large Entity) Applicant(s): Masatomo Shibata et al.						Docket No. 23165	
Application No.	Filing Date	Examiner		Customer 1	No.	Group Art Uni	t Confirmation No.
10/519,152	August 10, 2005	Trang Q. Tran		23389		2811	5477
Invention: POROUS SUBSTRATE AND ITS MANUFACTURING METHOD, AND GAN SEMICONDUCTOR MULTILAYER SUBSTRATE AND ITS MANUFACTURING METHOD							
COMMISSIONER FOR PATENTS:							
Transmitted herewith is an amendment in the above-identified application.							
The fee has been calculated and is transmitted as shown below.							
CLAIMS AS AMENDED							
	CLAIMS REMAINING	HIGHEST#	NUMBE	ER EXTRA		RATE	ADDITIONAL
	AFTER AMENDMENT	PREV. PAID FOR	CLAIMS	PRESENT	<u> </u>		FEE
TOTAL CLAIMS	17 -	20 =		0	х	\$52.00	\$0.00
INDEP. CLAIMS	6 -	6 =		0	x	\$220.00	\$0.00
Multiple Dependen	nt Claims (check if appl	licable) 🗆					\$0.00
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT \$0.00							
Please cha A check in A check in The Directe communica Any a Any p Payment b WARNING: included o Paul J. Esatto, Jr. Registration No. 36	ation or credit any ove additional filing fees reconstant application processory credit card. Form PT: Information on this on this form. Provide Signature 0,749 T, MURPHY & PRESSIPlaza - Suite. 300	to cover the filing d to charge payment of erpayment to Deposit Acquired under 37 C.F.R. essing fees under 37 CfTO-2038. form may become purcredit card informatio	the folloccount 1.16. FR 1.17. ablic. Creon and a Dated:	enclosed. pwing fees a 19-1013/SS edit card in authorization July 15, 2 py certify that ited States Ponail in an envel	sMP nforr non or 2009 this ostal lope a	mation should n PTO-2038. correspondence Service with suit addressed to "Co	
(516) 742-4343 cc:	Signature of Person Mailing Correspondence						